

**AMENDMENTS TO THE CLAIMS:**

This listing of claims will replace all prior versions, and listings, of claims in the application:

**LISTING OF CLAIMS:**

1. (Original) A photosensitive resin composition containing a high molecular compound having at least a) a fluoro aliphatic group, and b) a group represented by formula LP (wherein L represents a divalent organic group connected to the skeleton of the high molecular compound, and P represents an aromatic group having a carboxyl group at the ortho-position).

2. (Canceled)

3. (Original) A photosensitive lithographic printing plate comprising a support having coated thereon a photosensitive layer containing the following components (a), (b) and (c),

(a) an o-naphthoquinonediazide compound,

(b) a resin soluble in an alkaline aqueous solution, and

(c) a polymer having a (meth)acrylate monomer having two or three perfluoroalkyl groups having from 3 to 20 carbon atoms in the molecule as a polymer component.

4. (Original) The photosensitive lithographic printing plate as claimed in claim 3, wherein the polymer (c) is a copolymer of the a (meth)acrylate monomer having two or three perfluoroalkyl groups having from 3 to 20 carbon atoms in the molecule and a (meth)acrylate monomer having an OH group.

5.-6. (Canceled)